

K.A

Notice of Allowability	Application No.	Applicant(s)	
	10/710,001	MO ET AL.	
	Examiner	Art Unit	
	Stanetta D. Isaac	2812	

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address--

All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. **THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS.** This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308.

- 1. ☒ This communication is responsive to the Ex parte Quayle filed on 2/6/06.
- 2. ☒ The allowed claim(s) is/are 1-22.
- 3. ☐ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
 - a) ☐ All b) ☐ Some* c) ☐ None of the:
 - 1. ☐ Certified copies of the priority documents have been received.
 - 2. ☐ Certified copies of the priority documents have been received in Application No. _____.
 - 3. ☐ Copies of the certified copies of the priority documents have been received in this national stage application from the International Bureau (PCT Rule 17.2(a)).

* Certified copies not received: _____.

Applicant has THREE MONTHS FROM THE "MAILING DATE" of this communication to file a reply complying with the requirements noted below. Failure to timely comply will result in ABANDONMENT of this application.
THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.

- 4. ☐ A SUBSTITUTE OATH OR DECLARATION must be submitted. Note the attached EXAMINER'S AMENDMENT or NOTICE OF INFORMAL PATENT APPLICATION (PTO-152) which gives reason(s) why the oath or declaration is deficient.
 - 5. ☐ CORRECTED DRAWINGS (as "replacement sheets") must be submitted.
 - (a) ☐ including changes required by the Notice of Draftsperson's Patent Drawing Review (PTO-948) attached
 - 1) ☐ hereto or 2) ☐ to Paper No./Mail Date _____.
 - (b) ☐ including changes required by the attached Examiner's Amendment / Comment or in the Office action of Paper No./Mail Date _____.
- Identifying indicia such as the application number (see 37 CFR 1.84(c)) should be written on the drawings in the front (not the back) of each sheet. Replacement sheet(s) should be labeled as such in the header according to 37 CFR 1.121(d).**
- 6. ☐ DEPOSIT OF and/or INFORMATION about the deposit of BIOLOGICAL MATERIAL must be submitted. Note the attached Examiner's comment regarding REQUIREMENT FOR THE DEPOSIT OF BIOLOGICAL MATERIAL.

Attachment(s)

- 1. ☒ Notice of References Cited (PTO-892)
- 2. ☐ Notice of Draftsperson's Patent Drawing Review (PTO-948)
- 3. ☐ Information Disclosure Statements (PTO-1449 or PTO/SB/08), Paper No./Mail Date _____
- 4. ☐ Examiner's Comment Regarding Requirement for Deposit of Biological Material
- 5. ☐ Notice of Informal Patent Application (PTO-152)
- 6. ☐ Interview Summary (PTO-413), Paper No./Mail Date _____
- 7. ☐ Examiner's Amendment/Comment
- 8. ☒ Examiner's Statement of Reasons for Allowance
- 9. ☐ Other _____


MICHAEL LEBENTRITT
SUPERVISORY PATENT EXAMINER

REASONS FOR ALLOWANCE

The following is an examiner's statement of reasons for allowance:

The closest prior art of record, Sato et al., US Patent 6,798,038, alone or in combination thereof, fails to show the following steps of:

Pertaining to independent claims 1 and 10, “ depositing a single deposition step an isolation insulator layer in said isolation apertures to a depth sufficient to fill said isolation apertures above said device layer by a first margin that is less than the thickness of said pad insulator...” and “etching said pad insulator layer with an etchant that does not attack said isolation insulator layer, whereby said pad insulator and said remaining portion of said isolation insulator layer are removed in the same step and said isolation plugs fill said apertures without CMP.”

Pertaining to independent claim 19, “etching said isolation insulator layer such that said sidewall thickness of said isolation insulator on said isolation aperture walls is removed and remaining isolation plugs of said insulator layer fill said apertures substantially coplanar with said device layer, without CMP” and “etching said pad insulator layer with an etchant that does not attack said isolation insulator layer, whereby said pad insulator and said remaining portion of said isolation insulator layer are removed in the same step and said isolation plugs fill said apertures without CMP.”

Pertaining to independent claim 21, “...performing before said step of forming set of apertures in areas of pad insulator...”

Art Unit: 2812

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Stanetta D. Isaac whose telephone number is 571-272-1671. The examiner can normally be reached on Monday-Friday 9:30am -6:30pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Michael Lebentritt can be reached on 571-272-1873. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see <http://pair-direct.uspto.gov>. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Stanetta Isaac
Patent Examiner
February 17, 2006


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SUPERVISORY PATENT EXAMINER